# Basic Study on High-Gradient Accelerating Structures at KEK / Nextef

Tetsuo ABE (KEK)

on behalf of Nextef group (T. Abe, T. Higo, Y. Arakida, S. Matsumoto, T. Takatomi)

HG2015 Workshop at Tsinghua University, Beijing, China 2015-06-19



### Research Strategy

#### **Multi-Cell Prototypes**

Electrical Design



**Mechanical Design** 



**Fabrication** 



**HG Test** 

- ✓ Comprehensive study and development
- ✓ Cost and time consuming

Based on NC **X-band technology**developed by SLAC-CERN-KEK collaboration



Solutions

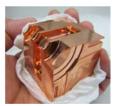
problems

Solutions

problems

Solutions





#### **Single-Cell Cavities**

**Design** → **Fabrication** → **HG Test** 

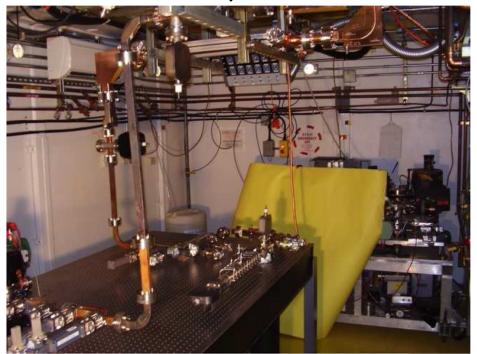
- ✓ Minimum structure keeping realistic RF fields for acceleration
- ✓ Basic study, element test
- ✓ Easy to make and test

V. A. Dolgashev, S. G. Tantawi, C. D. Nantista, Y. Higashi, and T. Higo, "Travelling wave and standing wave single cell high gradient tests," SLAC-PUB-10667, 2004.

Feedback

#### Nextef / Shield-B has been booted with support of SLAC and CERN.

SLAC / ASTA



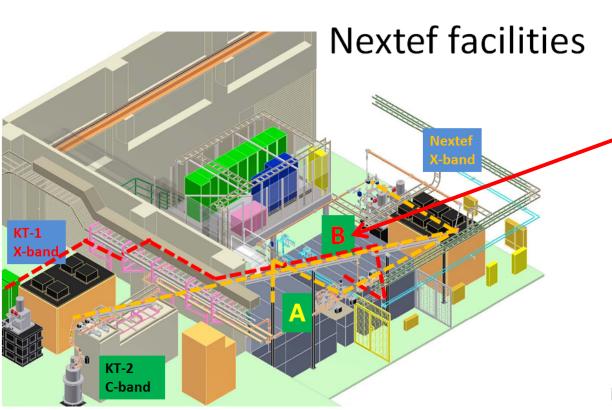
Tested many structures

KEK/ Nextef/ Shield-B



Now power-line conditioning

#### X-Band Single-Cell Test Stand for Basic Study: KEK/Nextef/Shield-B



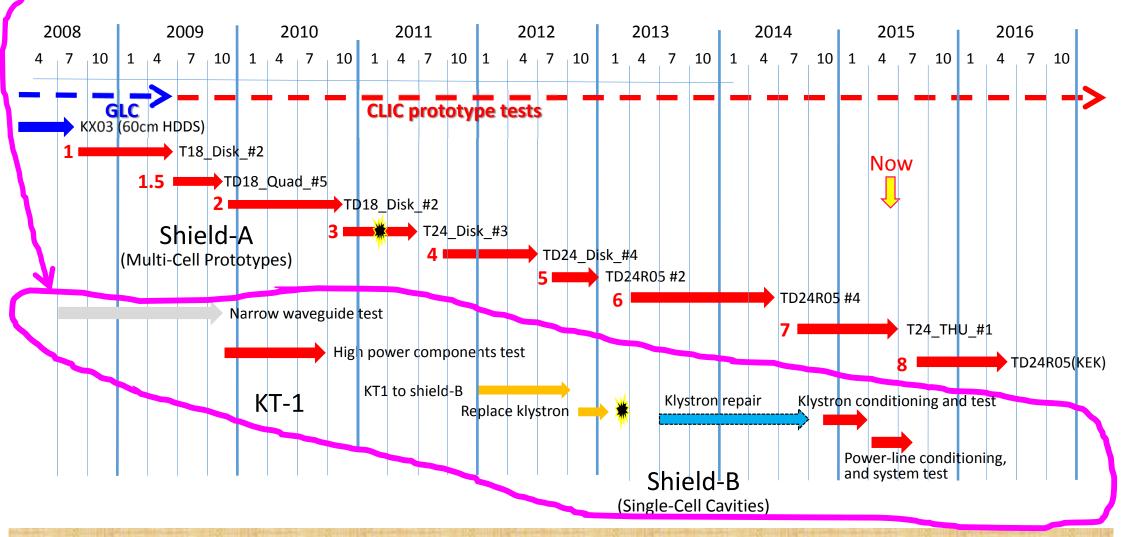




Example of test cavity setup



#### History and Plan at KT-1 and Nextef / Shield-B



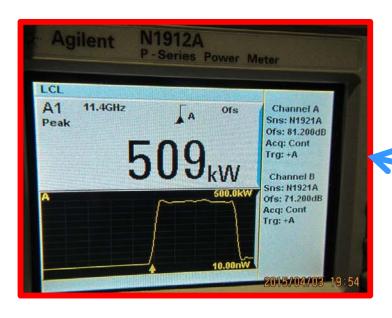
2015-06-19

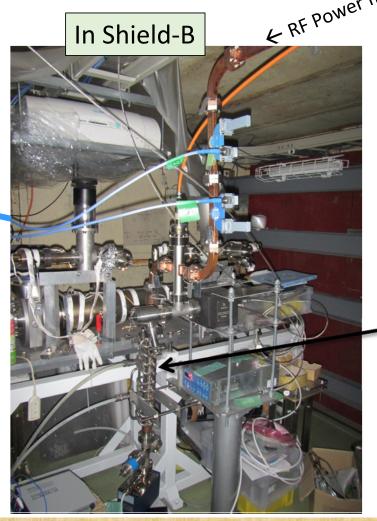
HG2015 (T. Abe, KEK)

#### RF Power from KT-1 has reached Shield-B.

-B.

ERF Power from KT-1 Klystron



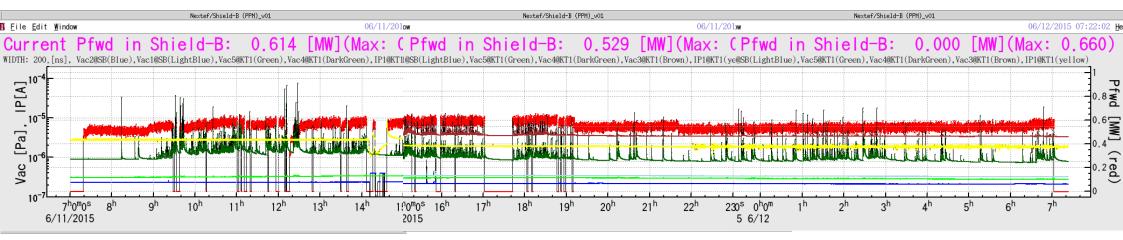


Dummy Load

## Example of Conditioning Histories of the Power Line

From 2015-06-11 7:00 to 2015-06-12 7:00

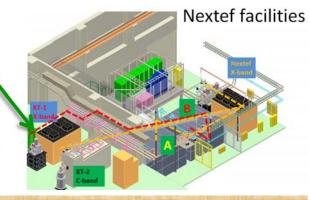
-- RF Power into the Dummy Load



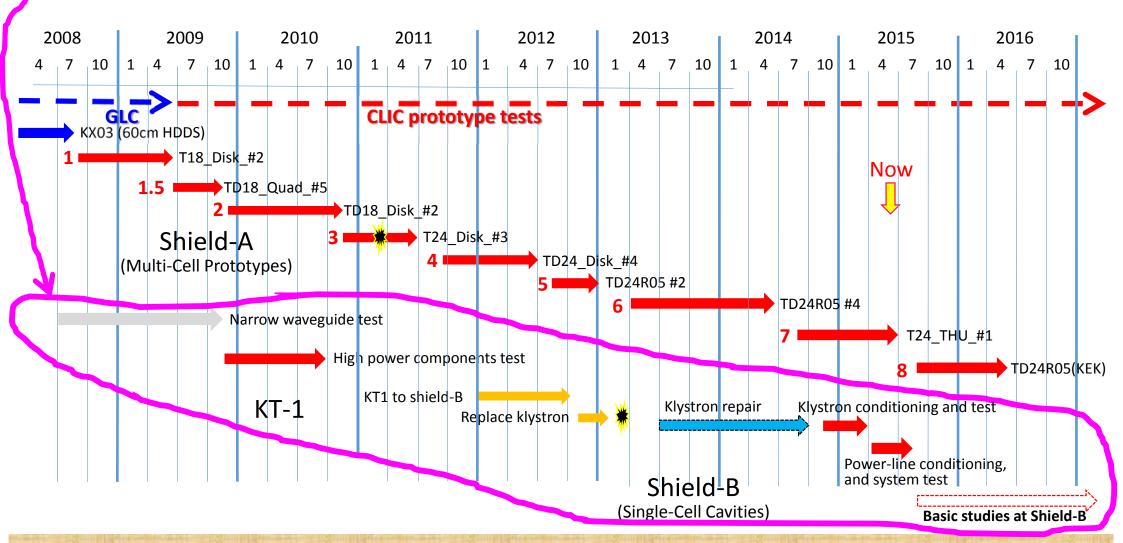
-- Vacuum at the low-loss line entrance

-- Vacuum near the dummy load in Shield-B

- Target at present: 10 MW
- $\blacksquare$  Manual  $\rightarrow$  Automatic conditioning for aggressive vacuum scrubbing



#### History and Plan at KT-1 and Nextef / Shield-B

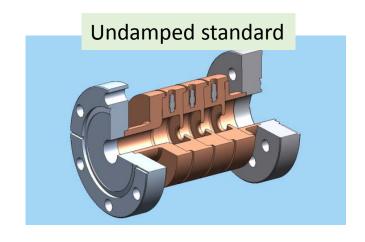


2015-06-19 HG2015 (T. Abe, KEK) 7

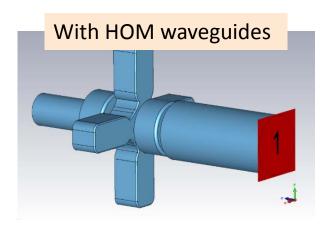
## **Test Structures**

### Single Cell Structures to be tested at Shield-B

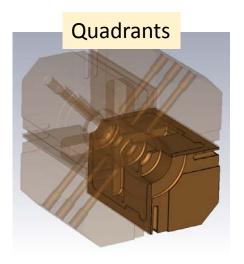
(Current list)



- With standard OFC (class1) and machined by turning
  - → For reference BDR
- With large grain
  - → To investigate grain-boundary effects



- Larger peak *H<sub>surf</sub>*
- To compare with undamped ones



- To investigate the relation between surface current and bonding surface
- Etc...

#### Disk type v.s. Quadrant type

#### Disk type





A damped disk

Disks stacked and bonded

#### ■ Advantages

- ✓ Machining by turning
- ✓ Very smooth surface (Ry: about 30nm)
- ✓ Shallow machining damage (< 1µm?)

#### ■ Disadvantages

- ✓ Ultra-high-precision machining of dozen of disks
   →Stack and bonding
- ✓ Great care
- ✓ Surface currents flow across disk-to-disk junctions.

#### **Quadrant type**





A Quadrant

Three Quadrants

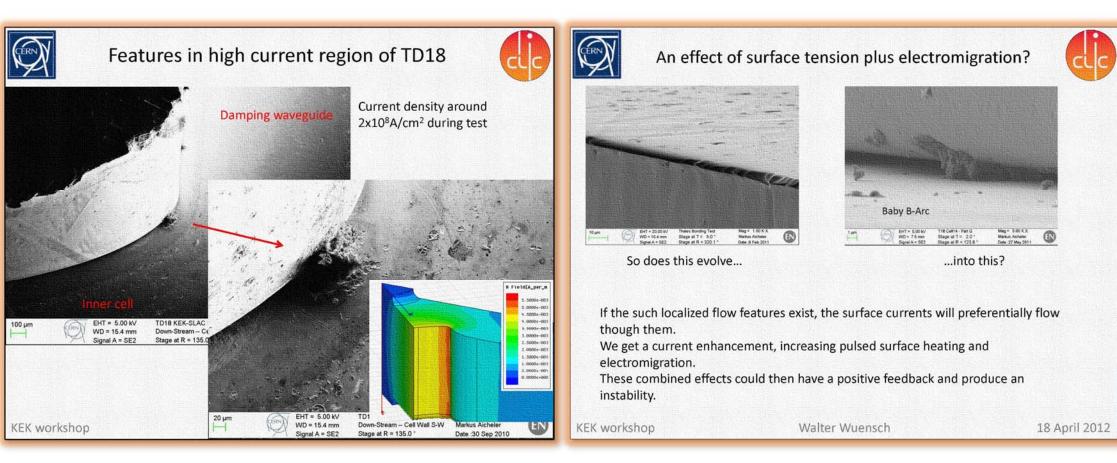
#### ■ Advantage

- ✓ No surface current flows across any junction or bonding plane.
- ✓ Simple machining by five-axes milling machines
- ✓ Simple assembly process
  - → Significant cost reduction?

#### ■ Disadvantages

- ✓ Not very smooth surface (Ry: about 1µm)
- ✓ Deep machining damage (10-20µm)
- ✓ Virtual leak from quadrant-to-quadrant junctions

## Suspicious-looking Objects Observed by Microscopy for Disk-type Structures

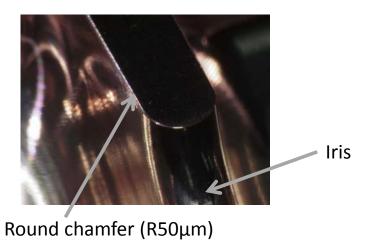


## Fabrication and Test of TD18\_Quad in 2009

Ultra-high precision milling (profile tolerance: 5µm)







High precision alignment (accuracy: 10μm)



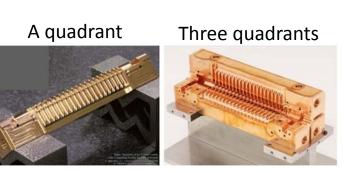


Put into a vacuum chamber



2015-06-19 HG2015 (T. Abe, KEK) 12

#### HG-Test Result of TD18\_Quad in 2009

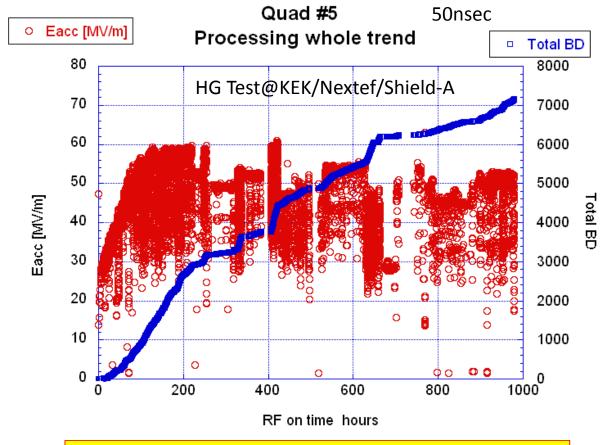




4 quadrants form a accl. str.



Into a vacuum chamber



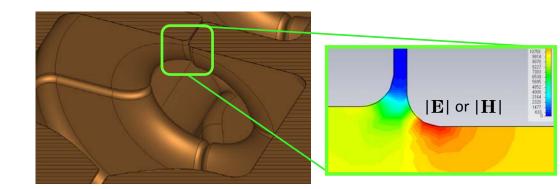


- ✓ Highest  $E_{acc}$ : 60MV/m (< 100 MV/m)
- ✓ No conditioning effect observed

Bad Performance

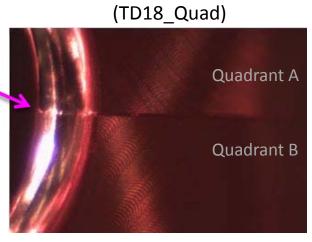
#### Disadvantages of the naïve quadrant-type structure:

- 1 Field enhancements
  - ← Misalignment of quadrants
  - ← Machining error

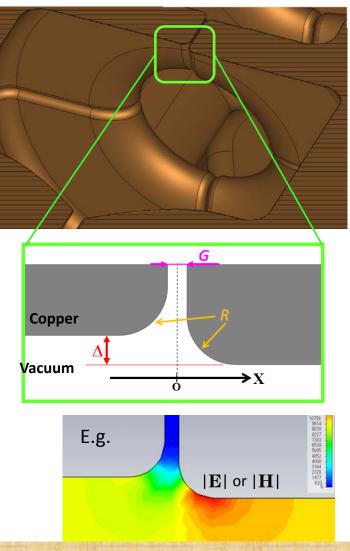


2 Virtual leak from between adjacent quadrants

- 3 Worse surface conditions by five-axes milling
  - > Thicker affected layer
  - $R_v > 1 \mu m$  (> skin depth of copper @ 11.4 GHz: ~0.5  $\mu m$ )



#### Field enhancements due to misalignment of quadrants

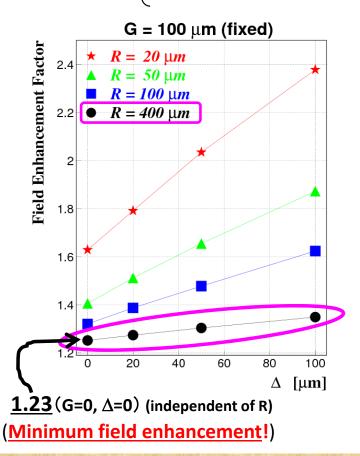


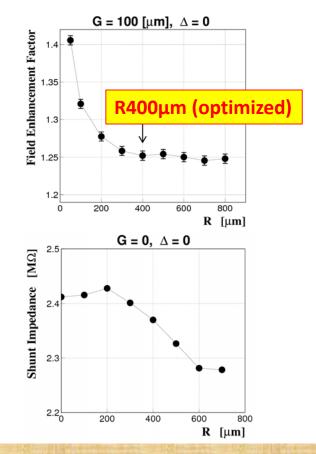
Numerically Calculated by the Floating Random Walk Method with Accuracies Better than 0.5%

For more details, see

T. Abe, "Study of Surface Field Enhancements due to Fine Structures,"

presented at the 8th Annual Meeting of Particle Accelerator Society of Japan, 2011 (Paper ID: TUPS086).





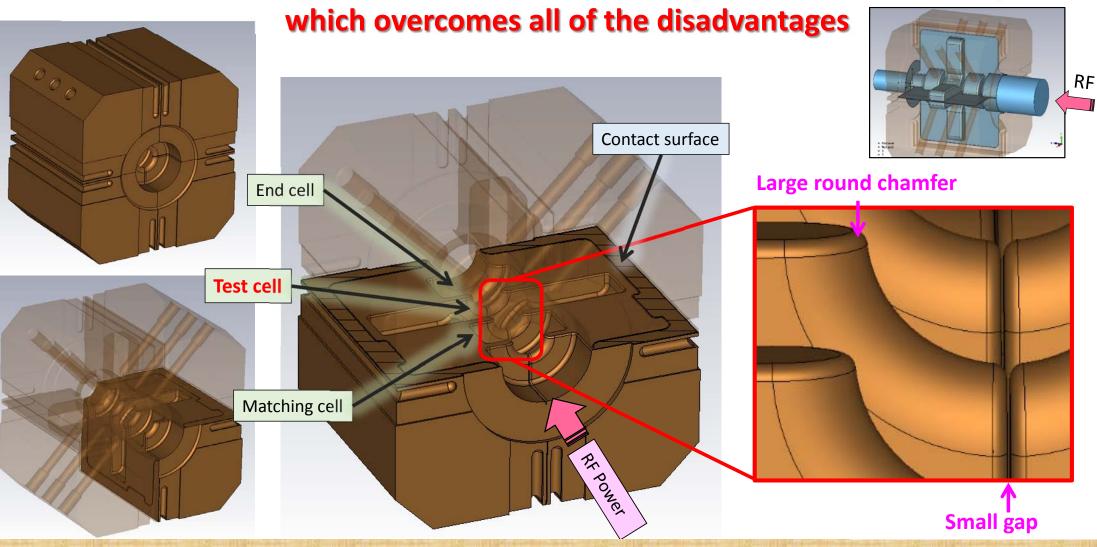
#### Overcoming the disadvantages of the naive quadrant-type

For more details, see

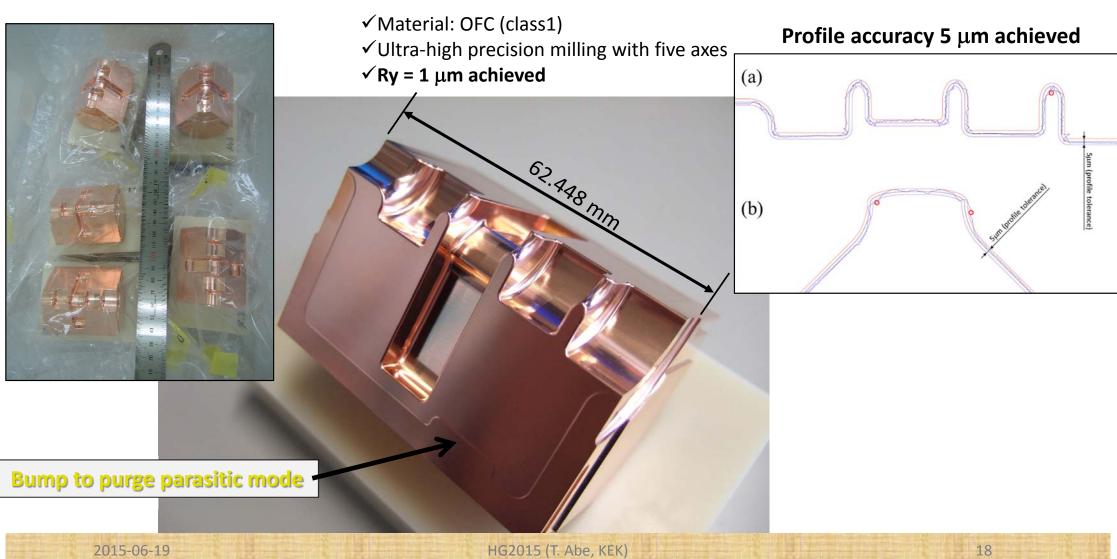
T. Abe et al., "Fabrication of Quadrant-Type X-Band Single-Cell Structure used for High Gradient Tests," presented at the 11th Annual Meeting of Particle Accelerator Society of Japan, 2014 (Paper ID: SUP042).

- (1) Field enhancements due to misalignment of quadrants, etc.
  - → Large round chamfer (R0.4mm)
- (2) Virtual leak from quadrant-to-quadrant junctions
  - → Small gap (0.1mm) between quadrants
- Worse surface conditions by five-axes milling
  - → Advanced polishing

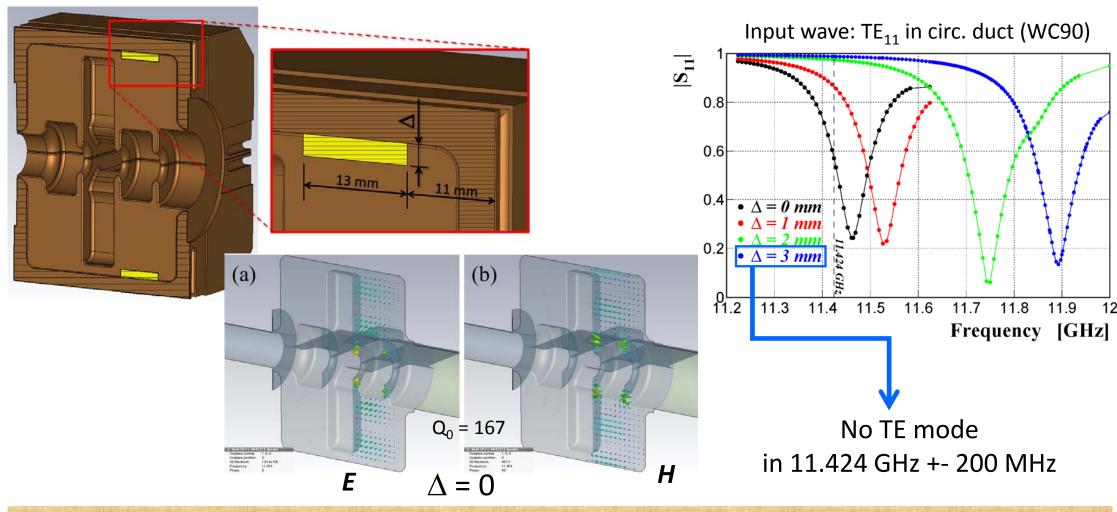
## Quadrant-type structure as a single-cell test cavity



#### Delivered Quadrants for HG Test

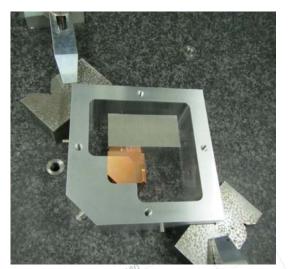


### TE mode near 11.424GHz to be purged

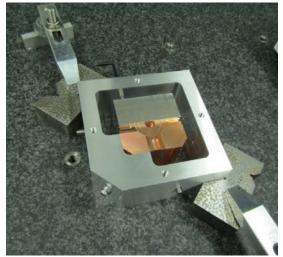


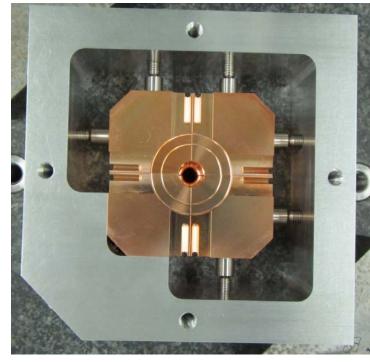
2015-06-19 HG2015 (T. Abe, KEK) 19

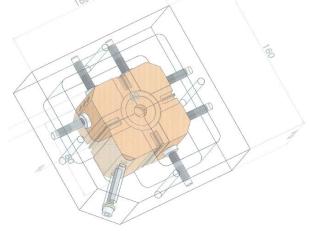
## Precise Assembly of Quads for EBW in 2015

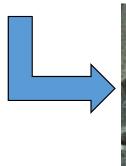


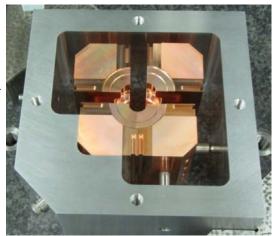


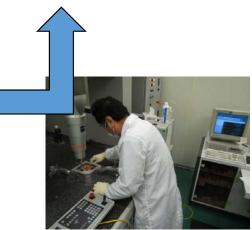








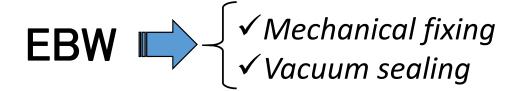




2015-06-19

HG2015 (T. Abe, KEK)

20

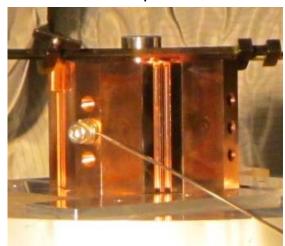


- 1. ~10<sup>-2</sup> Pa during the EBW
- 2. Max. Temp: 42 degC,  $\Delta T < 10 \text{degC}$  during the EBW
- 3. No vacuum leak verified

#### 1. EBW in operation



2. Thermocouple attached



3. Vacuum leak test just after the EBW

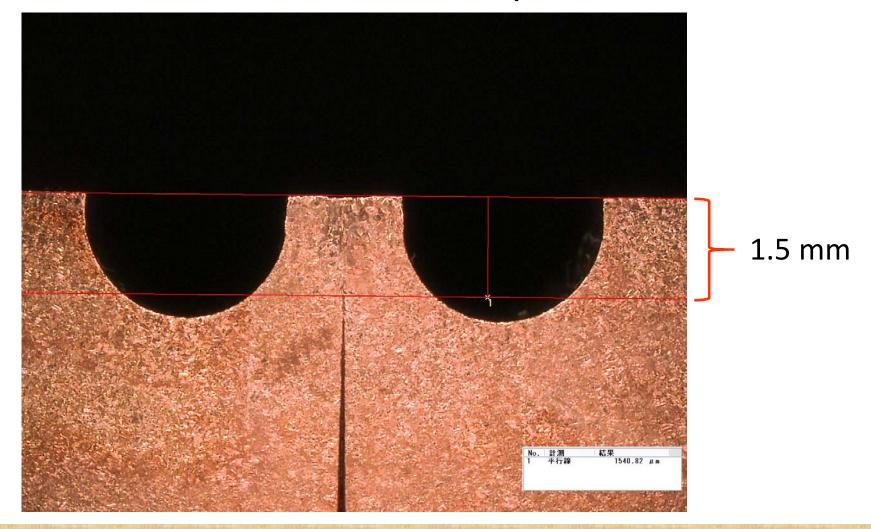


#### **After the EBW**



2015-06-19 HG2015 (T. Abe, KEK) 21

## Weld Penetration Depth



## Frequency Measurement

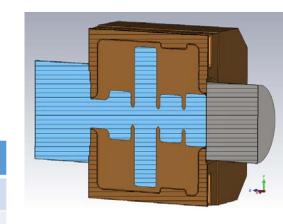
before and after the EBW

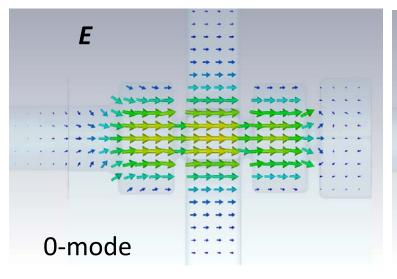
Pickup antenna

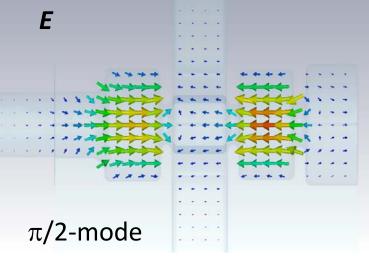


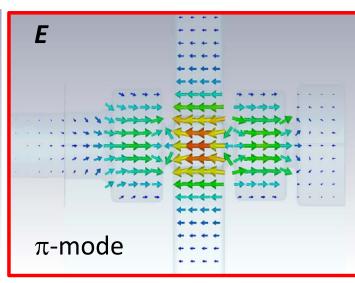
#### Measurements of the Mode Frequencies

Mode	After the EBW	Before the EBW	After - Before
0	11.2872 GHz	11.2739 GHz	+13.3 MHz
π/2	11.3362 GHz	11.3259 GHz	+10.3 MHz
π	11.4160 GHz	11.4104 GHz	+5.6 MHz

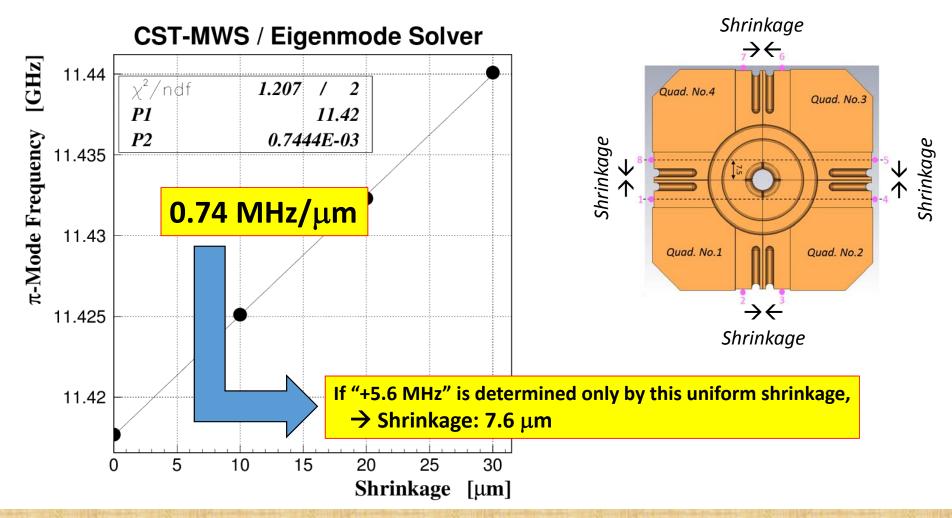








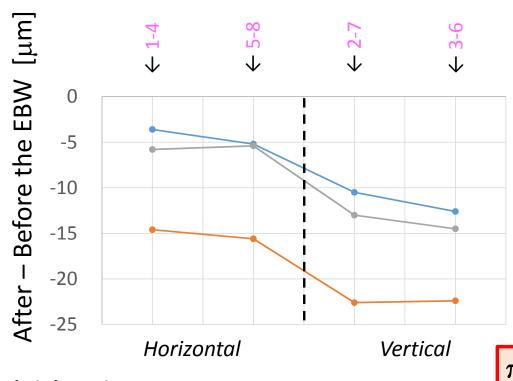
### Shrinkage Dependence of the $\pi$ -mode Frequency

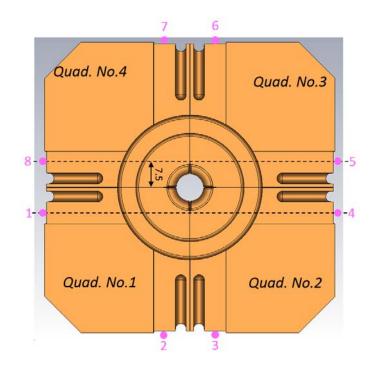


2015-06-19 HG2015 (T. Abe, KEK) 25

#### Length change in the transverse plane

#### Meas. Pos.

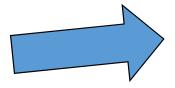




#### Shrinkage in average

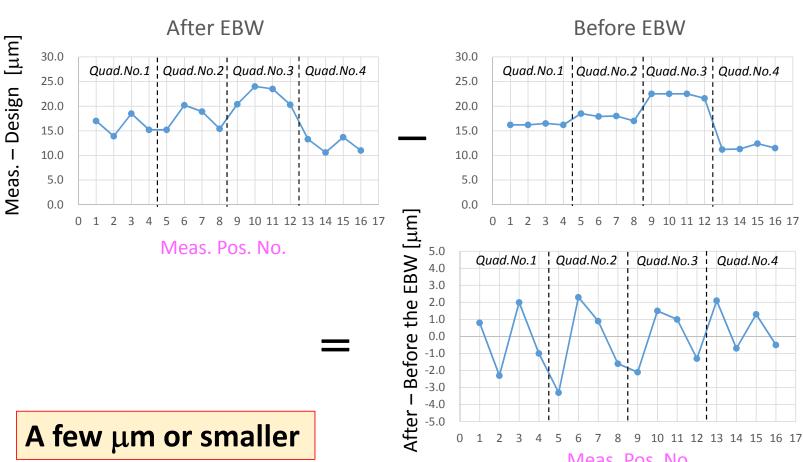
Cut-off side: 8.0 μm in averageRF-input side: 18.8 μm in average

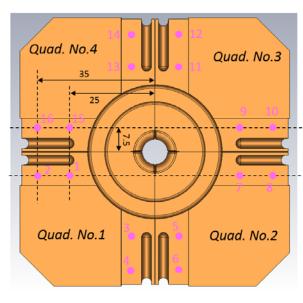
• Middle: 9.7 μm in average



 $\pi$ -mode frequency change can be attributed to transverse length change (shrinkage) at the contact surface of the adjacent quadrants.

#### Length change along the beam axis



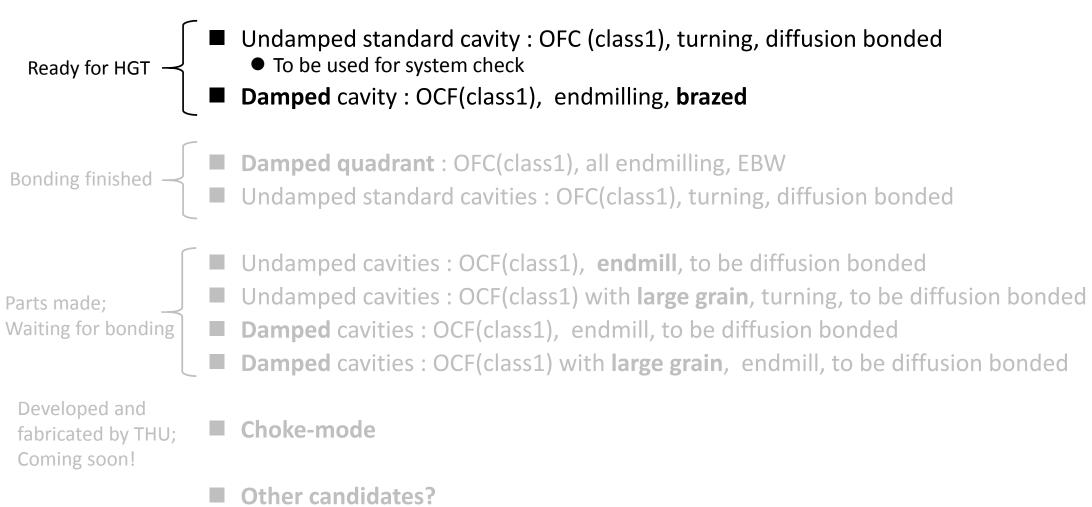


Meas. Pos.

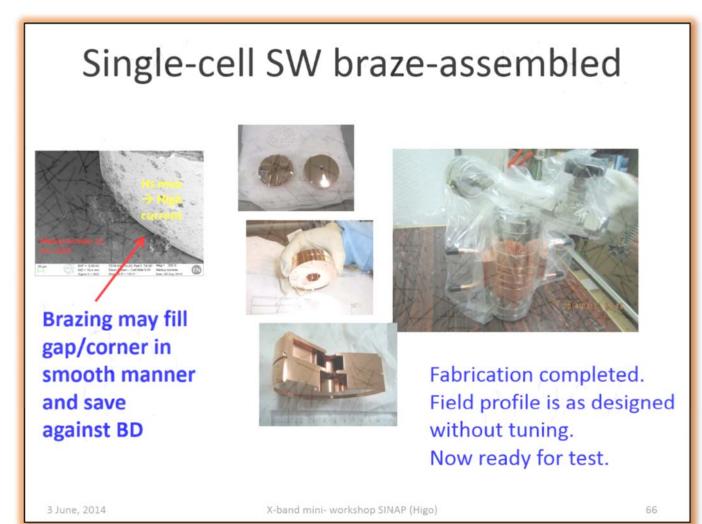
Meas. Pos. No.

HG2015 (T. Abe, KEK) 2015-06-19 27

### Structures to be tested at Nextef / Shield-B

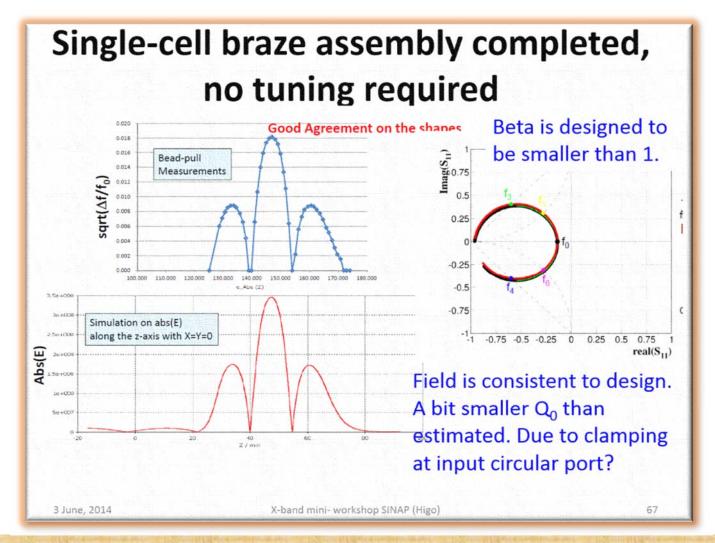


## Damped cavity: OCF (class1), endmilling, brazed

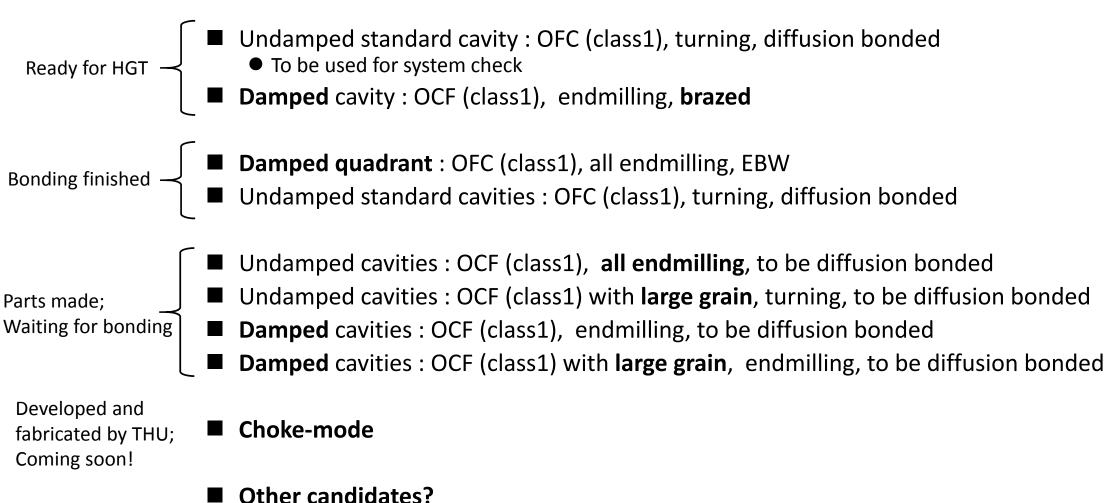


2015-06-19 HG2015 (T. Abe, KEK) 29

## Damped cavity: OCF (class1), endmilling, brazed



### Structures to be tested at Nextef / Shield-B



2015-06-19 HG2015 (T. Abe, KEK) 31

### Research Policy and Plan

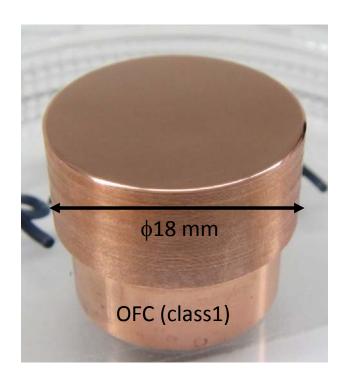
- The 1<sup>st</sup> HG test for the undamped standard cavity
  - Just after this summer shutdown
  - Measure reference BDR
  - Start with  $E_{acc} = 80 120 \text{ MV/m}$  region for actual application
  - Step up for higher E<sub>acc</sub>, depending on the results and our interests
- Next cavity
  - Undamped cavity with all-endmilling or large grain, or
  - Choke-mode cavity (from THU)

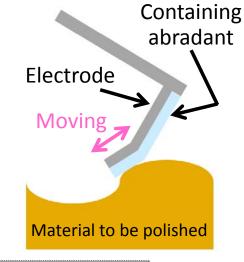
## **Surface Finishing for Quadrants**

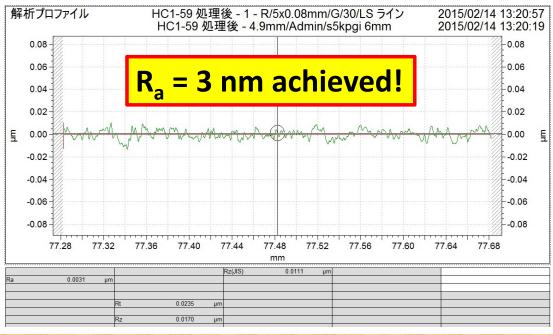
### Polishing Test for Ultra-Smooth Surface

Usual electro-polishing cannot be applied to complicated surfaces.

→ <u>Electrical + Mechanical</u> polishing can be applied to any curved surface in principle

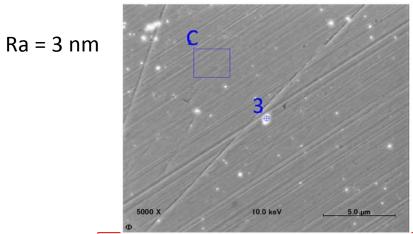




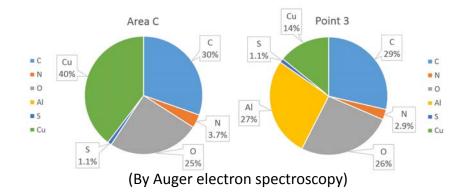


### Surface Check by Microscopy

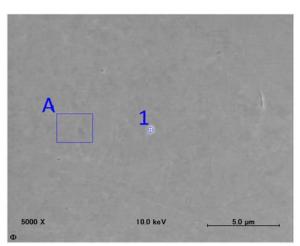
"Electrical + Mechanical" polishing with Alumina abradant only



A lot of scratches and abradant



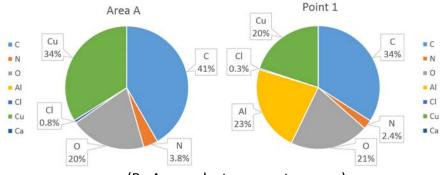
Advanced method based on "Chemical + Mechanical" polishing



Ra = 1 nm!

Small scratches, few abradant

Promising Method!



(By Auger electron spectroscopy)

#### Summary

- ■Basic study, in the form of single cell, based on the X-band technology developed so far, is beginning at KEK / Nextef / Shield-B.
  - √ The klystron (KT-1) is working well.
  - √ The power-line conditioning is on-going.
  - ✓ The 1<sup>st</sup> HG test will start just after this summer shutdown.

#### ■Structures to be tested

- Undamped standard, all turning or all endmilling
- Damped structures with HOM waveguides or choke-mode
- New quadrants
- With large grain
- Others?

Thank you for your attention!